

10 x 10mm, 500µm Pitch, 2.2° Div., Cyl. Microlens Array, UV-VIS



Stock **#72-602** [CONTACT US](#)

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S\$1,311^{.00}

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Volume Pricing	
Qty 1-10	S\$1,311.00 each
Qty 11-25	S\$1,053.00 each
Qty 26-49	S\$983.00 each
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Product Downloads

General	
Lens Array	Type:
Physical & Mechanical Properties	
10.0 x 10.0 ±0.05	Dimensions (mm):
3.000	Radius R (mm):

1.20 ±0.05	Thickness (mm):
Optical Properties	
6.60	Effective Focal Length EFL (mm):
Fused Silica (Corning 7980)	Substrate: □
UV-NIR (250-700nm)	Coating:
250 - 700	Wavelength Range (nm):
Coating Specification: R _{abs} ≤1.0% from 350 - 450nm @ 0° AOI R _{avg} ≤1.5% @ 250 - 700nm @ 0°	
±2.2	Divergence Angle (°):
500.00 ±0.25	Pitch (µm):
Single-Sided	Array Type:

Regulatory Compliance	
Compliant	RoHS 2015:
View	Certificate of Conformance:
Compliant	Reach 250:

Product Details

- Generate Non-Gaussian Line Patterns
- Ideal for Light Homogenization
- Excellent Performance from 193nm – 2.5µm

Cylindrical Microlens Arrays are used to homogenize a variety of light sources, including lasers or high power LEDs. Unlike [Square Microlens Arrays](#), which generate spot patterns, Cylindrical Microlens Arrays yield non-gaussian line patterns, and are ideal for welding, drilling, or laser ablation applications from the UV to IR. Cylindrical Microlens Arrays are available uncoated, VIS-NIR, or UV-NIR coated, including options with lenses on a single side for line generation applications or double-sided (with cross-oriented lenses) for beam homogenisation. Additionally, these lenses can be used as fast axis collimators.